## Supplementary Materials: Deposition of magnetite nanofilms by pulsed injection MOCVD in magnetic field

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## 1. X-Ray diffraction results



**Figure S1.** X-ray diffraction scans of Fe<sub>3</sub>O<sub>4</sub> films grown at different temperatures on Al<sub>2</sub>O<sub>3</sub>(0001). In the legend, c indicates that the films were grown without a magnetic field and cooled in 1 T and c + g indicates that the films were grown *and* cooled in a 1 T field.

Table C1 The	arrowa and amain	aina calaulatad	for Early films		Al-O- or hotroto
Table 51. The	e average grain	size calculateu	<b>IOF FE3U4</b> IIIIIIS	grown on	AI2O3 SUDSIFILE.
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Average grain size, (nm)						
T deposition, (°C)	Grown in Ar	Grown in H2+Ar				
450	15.7					
450	15.7					
450, 1T	17.4					
500	14.2	11.1				
500, cooled in 1T	12.7	_				
500, 1T	13.4	11.2				
550	14.1	12.3				
550, cooled in 1T	_	_				
550, 1T	15.1	11.3				





Figure S2. Phi scan of the (511) reflection for a Fe<sub>3</sub>O<sub>4</sub> film on MgO(100).[1].

**Table S2** The FWHM, rocking curve, *a* lattice parameter, and average grain size values of the Fe<sub>3</sub>O<sub>4</sub> films on MgO substrate.

T deposition,	FWHM, (°)	Omega	a lattice	Average				
(°C)		FWHM, (°)	parameter,	grain size,				
			(Å)	(nm)				
Fe <sub>3</sub> O <sub>4</sub> grown in Ar atmosphere								
450	0.66	0.68	8.340	13.7				
450, 1T	0.72	0.84	8.337	12.5				
500	0.56	0.83	8.318	16.1				
500 cooled in	0.53	0.79	8.315	17.2				
1T								
500, 1T	0.58	0.79	8.312	15.6				
550	0.72	0.56	8.301	12.5				
550 cooled in	0.69	0.68	8.293	13.0				
1T								
550, 1T	0.79	0.64	8.302	11.5				
600	0.53	0.66	8.284	17.1				
600, 1T	0.93	0.68	8.300	9.8				
Fe <sub>3</sub> O <sub>4</sub> grown in Ar+H <sub>2</sub> atmosphere								
500	0.49	0.68	8.362	10.5				
500, 1T	0.51	0.71	8.360	11.3				
550	0.86	0.69	8.352	18.3				
550, 1T	0.80	0.57	8.348	17.9				

2. Scanning electron microscopy (SEM) results





450ºC,1T



500ºC

500ºC,1T



550ºC

550ºC,1T



600ºC

600ºC,1T

**Figure S3.** SEM images of Fe<sub>3</sub>O<sub>4</sub> films on Al<sub>2</sub>O<sub>3</sub>(0001) substrates grown in Ar atmosphere. The images in the left and right column correspond to films grown without and with a magnetic field, respectively. All scale bars are  $1\mu m$ .





500ºC

500ºC,1T





**Figure S4.** SEM images of Fe<sub>3</sub>O<sub>4</sub> films on MgO(001) substrates grown in Ar atmosphere. The images in the left and right column correspond to films grown without and with a magnetic field, respectively. All scale bars are  $1\mu m$ .



**Figure S5**. In-plane (left) and out-of-plane (right) hysteresis curves of Fe<sub>3</sub>O<sub>4</sub> films grown on MgO substrates at 550°C with and without an external magnetic field of 1 T. The blue data points indicate the effect of cooling in an external magnetic field of 1 T.[1]

## References

1. Zukova, A.; Teiserskis, A.; Gun'ko, Y.K.; Sanchez, A.M.; van Dijken, S. Anomalous magnetic field effects during pulsed injection metal-organic chemical vapor deposition of magnetite films. Applied Physics Letters 2010, 96.